

Power Semiconductors Business Strategies

May 26, 2014

Fuji Electric Co., Ltd.

Electronic Devices Business Group



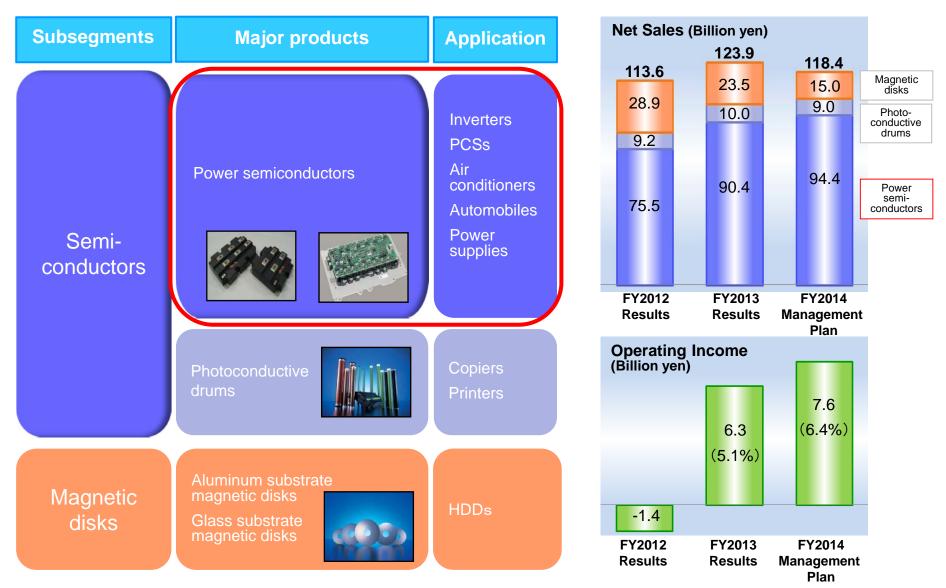
- Business Overview
- Market Trends
- Business Targets
- Priority Measures



Business Overview

Electronic Devices Segment





Power Semiconductors Business Overview



(FY2013)

Industrial field (47% of total sales)

Automotive field (35% of total sales)

Power supply field (18% of total sales)

Application



conditioners, etc.

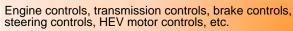




Discrete products

Pressure sensors

Power ICs







Industrial equipment, communication equipment, servers, PCs, flat-screen TVs, video game consoles, copiers, printers, etc.

Products



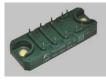
reliability

IGBT modules SiC modules

Inverters, NC machine tools, elevators, UPSs,

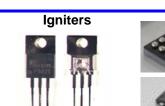
PCSs (wind / solar power generation), air

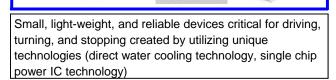












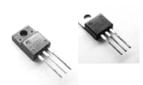




Power supply control ICs

Diodes

MOSFETs





High-voltage, low-loss power supply IC and SJ-MOS*1 technologies that respond to ever stricter energy saving standards for power supplies

Unique devices that greatly improve power

conversion efficiency (SiC, RB-IGBT) and

packaging technologies that realize high



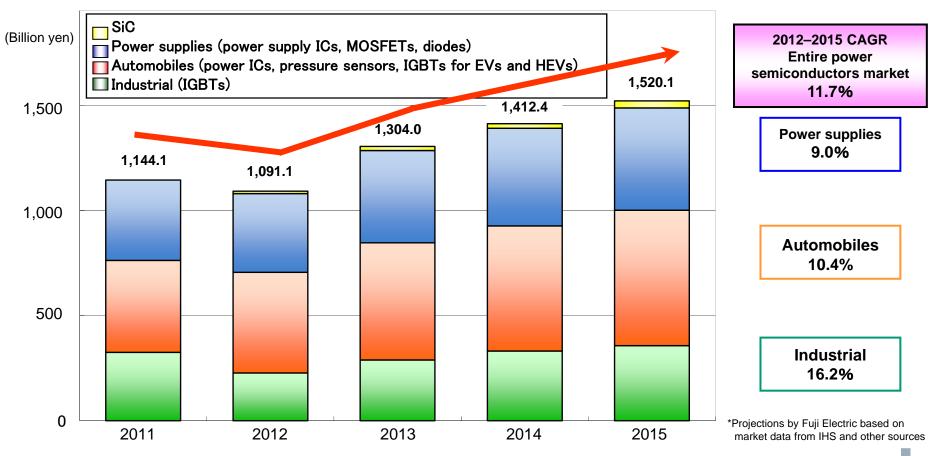
Market Trends

Power Semiconductors



Market Trends(Market in which Fuji Electric Participates)^{Innovating Energy Technology}

- Market contraction in FY2012, average growth rate of 12% projected for FY2013 onward
- Expansion in domestic markets for EVs, HEVs, and industrial equipment and overseas markets for industrial equipment, consumer electronics, new energy, and eco-friendly vehicles

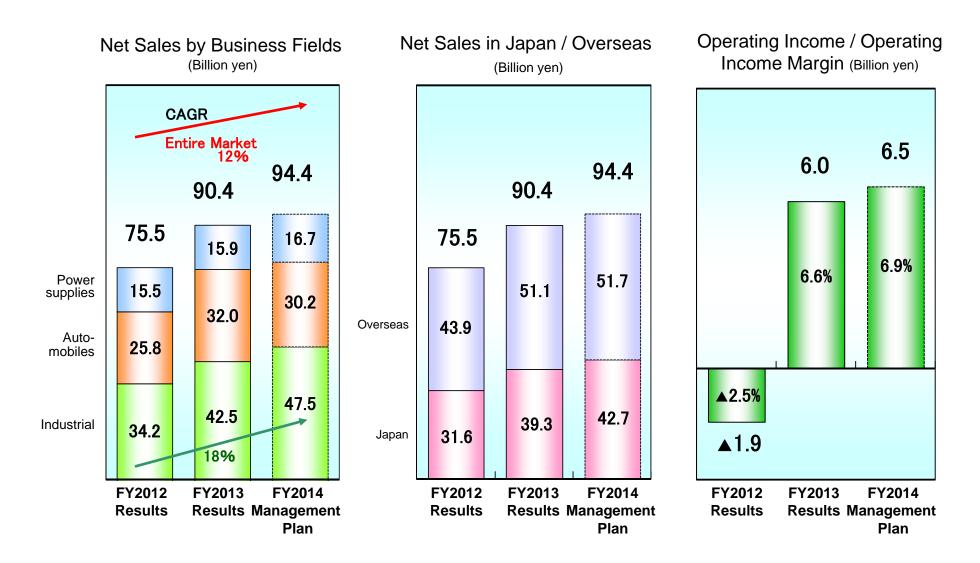




Business Targets

Power Semiconductor Business Targets







Priority Measures

Power Semiconductor Priority Measures



Basic Policy

- Development of foundation for Accomplishing Goals "Sales Target 100 billion yen" of FY2015
 Medium-Term Management Plan
- Realization of 7% operating margin
- Accelerate development and Strengthen R&D structure
- Optimize global operations and improve cost competitiveness

Priority Measures

- Expand sales
 - -Increase sales and expand market share by launching new products (⇒ Accelerate development)
- -Increase sales through the enhanced local design in the Design Center (China / Taiwan / Europe)
- Accelerate development of next-generation power semiconductors
- -Accelerate development of SiC product (commence mass production)
- Accelerate development of 7th generation IGBT (X-Series)
- Establish the optimal production structure to increase production
- -Expand production on front-end process
- -Expand overseas production on back-end process (overseas production ratio 39% (FY2013), 47% (FY2014))
- -Step up overseas parts procurement (overseas procurement ratio 32%(FY2013),40%(FY2014))
- Strengthen R&D structure
- -Aggregation of technology and development department by the construction of the Development Center(Matsumoto Factory) (Completion of new building in March 2015)



Industrial Field Overview of New Products



- ☐ Begin market launch of new products (including newly derived products) that achieve increasing levels of power conversion efficiency
 - By taking advantage of their individual features, aim to boost market share in target fields
- Use RB-IGBT and SiC devices employing our proprietary technologies to achieve low loss levels
- Enable easy application in compact and high-radiation packages

Target	New Products	Features	Mass Production Timing
PCSs for Solar Power generation systems, UPSs	AT-NPC modules (RB-IGBT)	Simple external wiring, low surge voltage, low loss	Two models under mass production, series expansion from November 2014
General-purpose Inverters,	Small PIMs (V-Series)	Compact and lightweight package, solderless mounting available	Under mass production
General-purpose Servo systems, Industrial air-	Small IPMs(V-Series)	Ultracompact package, includes drive IC and protection function	Under mass production for air conditioners, for industrial use from June 2014
conditioner, Motor drive in General	Motor drive in (V-Series+SiC-SBD)	Substantially reduced switching losses (such as 35%)	Under mass production
NC machine tools, General-purpose servo systems,injection molding machine	Medium capacity IPM, High heat dissipation type (V series)	Increased overload tolerance, extended life, more compact (down 25% from previous models)	600V from September 2014, 1200V from November 2014

*AT-NPC: Advanced T-type Neutral Point Clamped PIM: Power Integrated Modules IPM: Intelligent Power Modules



Automotive Field Overview of New Products

- ☐ Begin market launch of new products (including newly derived products) that are more compact, lightweight and reliable
- Achieve low loss levels by employing next-generation trench IPS technology
- Employ enhanced protection function to achieve high levels of reliability
- Meet diverse customer design needs by providing low-voltage sensors as series
- By increasing sensor sensitivity, extend application to fuel tanks

Target	New Products	Features	Mass Production Timing	
Control of relays, solenoids, lamps, etc.	High-side IPS	Enhanced protection function, low on resistance, highly sensitive current detection	from October 2014	
Control of motors, etc., relay substitute	High-current IPS	High L load tolerance, low on resistance, battery reverse-connection protection, auto-protection function	from January 2015	
Control of solenoids, stepping motors, etc.	Low-side IPS	Low resistance, high functionality, auto-protection function	Under mass production	
Sensing of intake pressure, overpressure	Intake pressure, overpressure sensor	Compact, lightweight, freeze-resistant	from August 2015	
Sensing of fuel tank pressure	Fuel leak detection sensor	Highly sensitive, increased fuel resistance	from June 2014	

Power Supply Field Overview of New Products



- ☐ Begin market launch of new products (including newly derived products) that achieve energy savings
- Low-loss, low standby power
- Product lineup capable of responding to diverse customer designs

Target	New Products	Features	Mass Production Timing	
LCD TV	Power factor control ICs	Improved efficiency in Low-load Enhanced protection function	from January 2014	
Printers	PWM control ICs	Low standby power Output current stabilization	from April 2013	
PC power	Quasi-resonant ICs	Sound prevention Low standby power	Under mass production	
supplies	Current resonance ICs	Low standby power, Highly efficient MOS crash prevention	from October 2013	
LED lighting	SJ-MOSFET (600V)	Low on resistance Low switching loss Low noise	Under mass production	
Servers	SiC SBD (650V, 1200V)	Low Vf* High avalanche tolerance Low switching loss	from 3Q 2014	
Standard power supplies	RB-IGBT (600V)	1-chip reverse blocking characteristic Low VCE(sat)* Ideal for AC switches	Under mass production	

^{*} Vf: Forward voltage on a diode; VCE(sat): IGBT on voltage

SiC Products



☐ Begin market launch of products that leverage features of SiC devices

- Accelerate development of application-specific SiC products

Major benefits

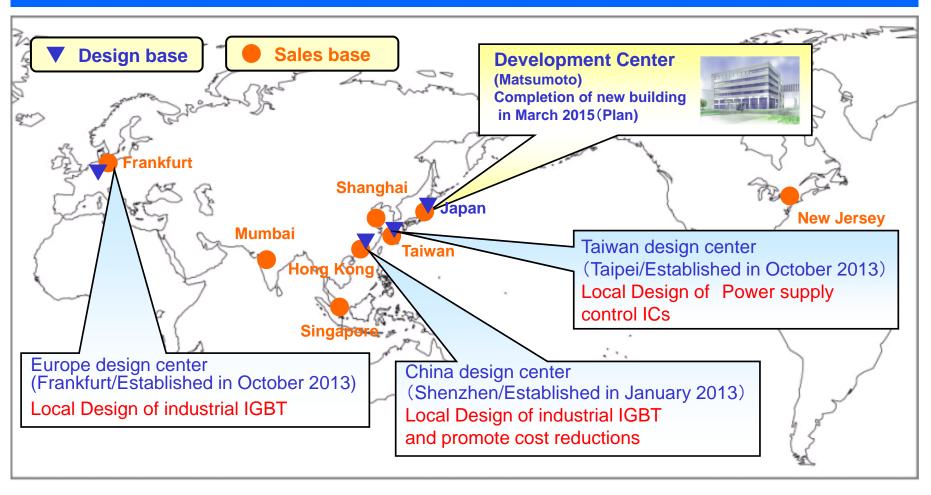
		Power Sour	ce App	lications	Drive Applications					
Features of SiC-Semiconductors	power s industri	General-purpose	General-purpose power supplies, industrial power sources	PCSs	Inverters		EV/		Electric Power	
		industrial power			Fans/ Pumps	Conveyors	Servo systems	HEV	Railcars	Infrastructure
	High-efficiency	0	0	0	0	0	0	0	0	0
Low-loss High-speed switching	Small / light- weight	0	0	0	0	0	0	0	0	0
	Highly accurate control					0	0			0
High-heat resistant	High reliability	0	0	0	0	0	0	0	0	0
/ High-voltage	Device voltage	600V/1.2kV/1.7kV					1.7/3.3kV	>3.3kV		

Product	Low capacity	Medium / large capacity		
SiC-SBD / SiC-MOSFET	SBD	All SiC	'15∼	
	discrete	Highly reliabl	le new power modules that are easy to connect in parallel	
Si IGBT+SiC Hybrid	6in1 7in1 modules		2in1 modules From the second half of FY2014	
			Under Mass production Under Development	

Boost Sales through Localization (Overseas Design Centers)



- Ostrengthen network of local bases that are design centers (China, Taiwan, Europe), accelerate product development to meet local needs, and work to increase local materials and component procurement ratios
- Establish the Development Center as the core global base for R&D



Plans for Production Bases in FY2014



Front-end processes: Increase scale of production and promote larger diameters Back-end processes : Boost overseas production ratio, expand mass production of automotive products overseas Production base (front-end processes) Production base (back-end processes) **Front-end process Back-end process** Matsumoto, Japan Tsugaru, Japan Japan (3 bases) **Philippines** In power semiconductors, Production base for accelerate production transfer of Fuji's products to power supply products (raise production ratio of Core global base power semiconductors to Core global base for front-end processes industrial and more than 50% by fiscal Shift to larger diameters (6, 8 inch)

Move to full-fledged mass production of SiC devices Yamanashi, Japan



Increase production of 8-inch IGBT series (full operation by fiscal year-end) **Malaysia**

year-end)

Expand IGBT series under production (boost overseas production ratio)



Increase production of industrial IGBT series



Expand production of automotive products

China (Shenzhen)



Produce industrial products for Chinese market Augment production capacity

Plant and Equipment Investment / R&D Expenditures



- Plant and equipment investment : shift focus from capacity expansion to R&D investment for new products and Next-generation products
- R&D expenditures : Next-generation products(SiC / 7th generation IGBT),
 accelerate development of new products

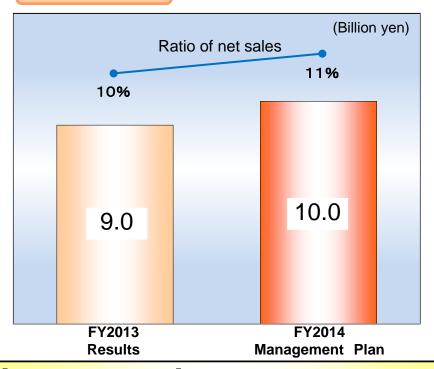
Plant and Equipment Investment



[Major themes in FY2014]

- ■Construction of Matsumoto development center (¥4.8 billion)
- ●Introduce 7th generation IGBT module development facility
- ●Introduce SiC device development facility

R&D Expenditures



[Major themes in FY2014]

- Develop SiC device mass production technology
- Develop 7th generation IGBT modules
- **●Expand series of industrial IGBT and power IC products**

[Development Center] Overview



Construct the Development Center at the Matsumoto Factory, our core global base for power semiconductor R&D and production technologies

Combine into this factory the technology and development divisions that are currently dispersed (enhance information sharing and collaboration)

[Accelerate product and technology development]

- Develop next-generation power semiconductors
- Develop high-value-added products
- Develop revolutionary production technologies

Display leading-edge technologies and products

Enhance our presence with customers

[Structural overview]

- Location : Matsumoto, Nagano Prefecture, Japan (within Fuji Electric's Matsumoto Factory)
- Structure : Steel frame, seismically isolated structure, six floors above ground
- Building area: Approximately 2,700 m2 (40m x 67m)
- Site area: 12,500 m2
- Investment: Approximately ¥4.8 billion
- Completion : March 2015 (plan)





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